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APPLICATION NO.	FILIN	G DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/789,423	02/27/2004		Harald Bottner	INFMN-021-1	5684	
52612	7590	09/20/2005		EXAMINER		
BEVER, HO		•	SANDVIK, BENJAMIN P			
BUILDING G			ART UNIT	PAPER NUMBER		
LIVERMOR	E, CA 945	50-6006		2826		

DATE MAILED: 09/20/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

			SY
	Application No.	Applicant(s)	<i>N</i>
	10/789,423	BOTTNER ET AL.	
Office Action Summary	Examiner	Art Unit	
	Ben P. Sandvik	2826	
The MAILING DATE of this communication ap	ppears on the cover sheet v	with the correspondence address	
Period for Reply	V 10 055 TO 5VDIDE - 1	MANUTURE OF THEFT (OA) DAY	
A SHORTENED STATUTORY PERIOD FOR REPI WHICHEVER IS LONGER, FROM THE MAILING I - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statu Any reply received by the Office later than three months after the maili earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUN. 136(a). In no event, however, may a d will apply and will expire SIX (6) MO te, cause the application to become a	ICATION. a reply be timely filed ONTHS from the mailing date of this communicated the com	
Status			
1) Responsive to communication(s) filed on 29	August 2005.		
·— · ·	is action is non-final.		
3) Since this application is in condition for allows	ance except for formal ma	tters, prosecution as to the merit	s is
closed in accordance with the practice under	Ex parte Quayle, 1935 C.	D. 11, 453 O.G. 213.	
Disposition of Claims			
4) Claim(s) <u>1-21</u> is/are pending in the application	n.		
4a) Of the above claim(s) <u>1,3 and 6-21</u> is/are		tion.	
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>2,4 and 5</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and/	or election requirement.		
Application Papers			
9)☐ The specification is objected to by the Examin	ner.		
·— · · _ · _	cepted or b) objected to	by the Examiner.	
Applicant may not request that any objection to the	e drawing(s) be held in abeya	ance. See 37 CFR 1.85(a).	
Replacement drawing sheet(s) including the corre	ction is required if the drawin	g(s) is objected to. See 37 CFR 1.12	21(d).
11)☐ The oath or declaration is objected to by the E	Examiner. Note the attach	ed Office Action or form PTO-152	2.
Priority under 35 U.S.C. § 119			
12)⊠ Acknowledgment is made of a claim for foreig	n priority under 35 U.S.C.	§ 119(a)-(d) or (f).	
a)⊠ All b)□ Some * c)□ None of:	, . ,	0 () () (-)	
1.⊠ Certified copies of the priority documer	nts have been received.		
2. Certified copies of the priority documer	nts have been received in	Application No	
3. Copies of the certified copies of the pri-	ority documents have bee	n received in this National Stage	
application from the International Burea	au (PCT Rule 17.2(a)).		
* See the attached detailed Office action for a lis	st of the certified copies no	t received.	
Attachment(s)	_		
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)		y Summary (PTO-413) o(s)/Mail Date	
3) 🗵 Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08	8) 5) Notice of	Informal Patent Application (PTO-152)	
Paper No(s)/Mail Date	6)	·	

DETAILED ACTION

Election/Restrictions

Applicant's election without traverse of claim 2, 4, and 5 in the reply filed on 8/29/2005 is acknowledged.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 2 and 5 are rejected under 35 U.S.C. 102(b) as being anticipated by Hayes (U.S. Patent #6077380).

With respect to **claim 2**, Hayes teaches a microelectromechanical component having at least one soldering layer for joining to at least one further component (Fig. 9a, the layer formed by balls 108), which component includes at least one soldering layer made from a solder comprising a eutectic mixture of gold and bismuth (Col 6 Ln 64 to Col 7 Ln 6).

With respect to **claim 5**, Hayes teaches a soldered joint including a solder comprising a eutectic mixture of gold and bismuth joins at least two components Fig. 9c, 112), wherein at least one component having an electrical functionality (Col 8 Ln 18).

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Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 4 is rejected under 35 U.S.C. 103(a) as being unpatentable over Hayes, in view of Kuramoto (U.S. PG Pub #2001/0020744).

With respect to **claim 4**, Hayes teaches all of the limitations of claim 2, but does not teach that at least one soldering layer, prior to the soldering operation, has a layer thickness of 100 nm to 10 micrometers. Kuramoto teaches a solder layer prior to soldering that has a thickness range of between 7 and 40 micrometers (Fig. 3, 14 and as set forth in claim 4). It would have been obvious to one of ordinary skill in the art at the time the invention was made to make the solder layer of Hayes to be 100 nm to 10 micrometers based on the teachings of Kuramoto in order to provide enough solder to make a reliable connection.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ben P. Sandvik whose telephone number is (571) 272-8446. The examiner can normally be reached on Mon-Fri.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan Flynn can be reached on (571) 272-1915. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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